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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
10/540,513	06/23/2005	Takenori Osada	Q88662	6641
23373 7590 03/19/2007 SUGHRUE MION, PLLC 2100 PENNSYLVANIA AVENUE, N.W. SUITE 800 WASHINGTON, DC 20037			EXAMINER	
			RODELA, EDUARDO A	
			ART UNIT	PAPER NUMBER
	,, 20 2000		2826	
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SHORTENED STATUTORY	PERIOD OF RESPONSE	MAIL DATE	DELIVERY MODE	
3 MONTHS		03/19/2007	PAPER	

Please find below and/or attached an Office communication concerning this application or proceeding.

If NO period for reply is specified above, the maximum statutory period will apply and will expire 6 MONTHS from the mailing date of this communication.

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	Application No.	Applicant(s)			
	10/540,513	OSADA ET AL.			
Office Action Summary	Examiner	Art Unit			
	Eduardo A. Rodela	2826			
The MAILING DATE of this communication app	pears on the cover sheet with the c	correspondence address			
Period for Reply		(O) OD THIRTY (OO) DAYO			
A SHORTENED STATUTORY PERIOD FOR REPL' WHICHEVER IS LONGER, FROM THE MAILING D.  - Extensions of time may be available under the provisions of 37 CFR 1.1 after SIX (6) MONTHS from the mailing date of this communication.  - If NO period for reply is specified above, the maximum statutory period or - Failure to reply within the set or extended period for reply will, by statute Any reply received by the Office later than three months after the mailing earned patent term adjustment. See 37 CFR 1.704(b).	ATE OF THIS COMMUNICATION 36(a). In no event, however, may a reply be tin will apply and will expire SIX (6) MONTHS from a, cause the application to become ABANDONE	N. nely filed the mailing date of this communication. (D. (35 U.S.C. § 133).			
Status					
1)⊠ Responsive to communication(s) filed on <u>07 D</u>	ecember 2006.				
·— ·	s action is non-final.				
Since this application is in condition for allowance except for formal matters, prosecution as to the merits is					
closed in accordance with the practice under E	Ex parte Quayle, 1935 C.D. 11, 4	53 O.G. 213.			
Disposition of Claims					
4)⊠ Claim(s) <u>1,2,4 and 5</u> is/are pending in the appl	lication.				
4a) Of the above claim(s) 4 and 5 is/are withdra					
5) Claim(s) is/are allowed.		doubtnitam			
6)⊠ Claim(s) <u>1 and 2</u> is/are rejected.					
7) Claim(s) is/are objected to.		Minhloan Tran			
8) Claim(s) are subject to restriction and/o	or election requirement.	Primary Examiner Art Unit 2826			
Application Papers		Art Offit 2820			
9) The specification is objected to by the Examine	er				
10) ☐ The drawing(s) filed on is/are: a) ☐ acc		Examiner.			
Applicant may not request that any objection to the					
Replacement drawing sheet(s) including the correct	tion is required if the drawing(s) is ob	jected to. See 37 CFR 1.121(d).			
11) ☐ The oath or declaration is objected to by the Ex	kaminer. Note the attached Office	Action or form PTO-152.			
Priority under 35 U.S.C. § 119		,			
12)⊠ Acknowledgment is made of a claim for foreign	priority under 35 U.S.C. & 119/a	)-(d) or (f)			
a)⊠ All b)☐ Some * c)☐ None of:	priority under 55 5.5.5. § 115(a)	, (a) 51 (i).			
1. ☐ Certified copies of the priority document	s have been received.				
2. Certified copies of the priority document		ion No			
3. Copies of the certified copies of the prio	rity documents have been receive	ed in this National Stage			
application from the International Burea	u (PCT Rule 17.2(a)).				
* See the attached detailed Office action for a list	of the certified copies not receive	ed.			
•	•				
Attachment(s)	o □ marino o com	(DTO 442)			
1) Notice of References Cited (PTO-892) 2) Notice of Draftsperson's Patent Drawing Review (PTO-948)	4)  Interview Summary Paper No(s)/Mail Da				
3) Information Disclosure Statement(s) (PTO/SB/08) Paper No(s)/Mail Date	5) Notice of Informal F 6) Other:	Patent Application			
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#### **DETAILED ACTION**

This Office Action is in response to the amendment filed December 7, 2006. It is acknowledged that claim 3 has been cancelled.

#### **Priority**

Receipt is acknowledged of papers submitted under 35 U.S.C. 119(a)-(d), which papers have been placed of record in the file.

## Claim Rejections - 35 USC § 102

The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless -

(b) the invention was patented or described in a printed publication in this or a foreign country or in public use or on sale in this country, more than one year prior to the date of application for patent in the United States.

Claims 1 and 2 are rejected under 35 U.S.C. 102(b) as being anticipated by Kuroda et al. (US 5,831,296).

Regarding claim 1, Kuroda et al. shows (e.g. Figure 3a) a compound semiconductor epitaxial substrate for use in a strain channel high electron mobility field effect transistor, comprising an InGaAs layer [5"/24] as a strain channel layer and an AlGaAs layer [4, column 4, lines 31-35] containing n-type impurities as an electron supplying layer, wherein said InGaAs layer has an electron mobility at room temperature of 8300 cm^2 / V\*s or more [column 5, lines 5-17],

wherein GaAs layers [3,21] having a thickness of 4 nm of more [layer 3 is 10 nanometers / 100 Angstroms as discussed on column 4: lines 27-32, and layer 21 is 1000 nm / 1 micrometer as discussed on column 4: lines 18-24] each are laminated

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respectively in contact with a top surface [3 is in contact with top surface of 5"/24] and a bottom surface [21 is in contact with bottom surface of 5"/24] of said strain channel layer [5"/24].

Regarding claim 2, Kuroda et al. disclose the compound semiconductor epitaxial substrate according to claim 1, as shown in Figure 3a, wherein the InGaAs layer constituting said strain channel layer [24] has an Indium composition of 0.25 or more [column 5, lines 5-17].

# Response to Arguments

Applicant's arguments filed December 7, 2006, have been fully considered but they are not persuasive.

In response to the assertion that Kuroda does not show the dimensions of the layers in contact with the strained channel layer, Kuroda clearly shows (e.g. Figure 3a) wherein GaAs layers [3,21] having a thickness of 4 nm of more [layer 3 is 10 nanometers / 100 Angstroms as discussed on column 4: lines 27-32, and layer 21 is 1000 nm / 1 micrometer as discussed on column 4: lines 18-24] each are laminated respectively in contact with a top surface [3 is in contact with top surface of 5"/24] and a bottom surface [21 is in contact with bottom surface of 5"/24] of said strain channel layer [5"/24].

#### Conclusion

THIS ACTION IS MADE FINAL. Applicant is reminded of the extension of time policy as set forth in 37 CFR 1.136(a).

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A shortened statutory period for reply to this final action is set to expire THREE MONTHS from the mailing date of this action. In the event a first reply is filed within TWO MONTHS of the mailing date of this final action and the advisory action is not mailed until after the end of the THREE-MONTH shortened statutory period, then the shortened statutory period will expire on the date the advisory action is mailed, and any extension fee pursuant to 37 CFR 1.136(a) will be calculated from the mailing date of the advisory action. In no event, however, will the statutory period for reply expire later than SIX MONTHS from the mailing date of this final action.

# Fax / Telephone Information

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Eduardo A. Rodela whose telephone number is (571) 272-8797. The examiner can normally be reached on M-F, 9:00AM-5:30PM.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Sue Purvis can be reached on (571) 272-1236. The fax phone number for the organization where this application or proceeding is assigned is 571-273-8300.

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Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free). If you would like assistance from a USPTO Customer Service Representative or access to the automated information system, call 800-786-9199 (IN USA OR CANADA) or 571-272-1000.

Eduardo Rodela

F.R.

Examiner